

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	150	((Yamazaki.in. or Inoue.in. or Miyanaga.in. or SEL.as. or (Semiconductor adj energy adj lab\$9)) and ((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with (plasma or glow or discharge or ECR))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:45
L3	21	((Yamazaki.in. or Inoue.in. or Miyanaga.in. or SEL.as. or (Semiconductor adj energy adj lab\$9)) and ((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with (plasma or glow or discharge or ECR) same (superpos\$8 or continuous\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:46
L4	103	((Yamazaki.in. or Inoue.in. or Miyanaga.in. or SEL.as. or (Semiconductor adj energy adj lab\$9)) and ((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with (coat\$4 or deposit\$4 or film or layer or \$4Cvd) same (superpos\$8 or continuous\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:46
L6	107	(Yamazaki.in. or Inoue.in. or Miyanaga.in. or SEL.as. or (Semiconductor adj energy adj lab\$9)) and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or deposit\$4 or coat\$4 or film or layer or \$4cvd or glow or discharge))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:48

L8	5	(Yamazaki.in. or Inoue.in. or Miyanaga.in. or SEL.as. or (Semiconductor adj energy adj lab\$9)) and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or deposit\$4 or coat\$4 or film or layer or \$4cvd or glow or discharge) same superpos\$10)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:49
L9	7403	(427/569,570,571,572,574,575, 578,582,583,584,248.1,255.23, 255.28,250,255.31,255.36,255.391,255.392,255.393).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/12/30 14:50
L10	1524	(118/723R,723MP,723MW, 723MA).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/12/30 14:50
L11	8642	L9 or L10	US-PGPUB; USPAT	OR	ON	2005/12/30 14:50
L12	304	427/571.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/30 14:51
L14	8642	L9 or L10	US-PGPUB; USPAT	OR	ON	2005/12/30 14:52
L15	256	L14 and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with (plasma or glow or discharge or ECR))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:52
L16	43	L14 and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with (coat\$4 or deposit\$4 or film or layer or \$4Cvd) with (superpos\$8 or continuous\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:53

L17	58	L14 and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or deposit\$4 or coat\$4 or film or layer or \$4cvd or glow or discharge))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:53
L18	4	L14 and (((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or deposit\$4 or coat\$4 or film or layer or \$4cvd or glow or discharge) same (superpos\$8 or overlap\$8 or onto or simultaneous\$7 or "same time"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:54
L19	8	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PECvd) same (superpos\$8 or overlap\$8 or onto or simultaneous\$7 or "same time") same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:54
L20	109	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PECvd) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:55

L21	109	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PEcvd) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:56
L22	109	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PEcvd) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:56
L23	126	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PEcvd) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:56
L24	17	L23 not L22	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:56
L25	22	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) with (frequency of electromagnetic or microwave or rf or vhf or wave)) with ((continuous\$4) with (superpos\$8 or overlap\$8 or combin\$7 or onto or simultaneous\$4 or "same time" or concurrent\$4)) same (plasma or glow or discharge or PEcvd) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:58

L26	95	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PEcvd) same (power or frequency) same (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 14:58
L28	187	(((pulse or pulsed or pulsing or intermittent\$4 or intermittant\$4 or discontin\$8 or (on near2 off)) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same ((continuous\$4) near3 (frequency of electromagnetic or microwave or rf or vhf or wave)) same (plasma or glow or discharge or PEcvd)) and (((metal\$2 or tungsten or ceramic or insulating or titanium or molybdenum or Ti or W or Mo or silicide) with (deposit\$4 or coat\$4 or film or layer or \$4cvd))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/30 15:00